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(54) Title: DEPOSITION OF NOBLE METAL ISLETS OR THIN FILMS FOR ITS USE FOR ELECTROCHEMICAL CATALYSTS
WITH IMPROVED CATALYTIC ACTIVITY

(57) Abstract: Platinum group metal containing chemical precursors suitable for vapor deposition are disclosed. Methods of using these
precursors for Platinum depositions are also disclosed. The chemical precursors and methods are particularly suitable for depositing
catalyst material on electrodes.

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